

L Number	Hits	Search Text	DB	Time stamp
1	23	(((trench\$2 groove\$3 window\$2 recess\$2)near21(sige silicon near2 germanium))same(compris\$4 form\$4 depos\$4 fill\$4 dislocation\$4 defect\$4)) and (lithograph\$4 etch\$4) and emitter and (H01L029/70 H01L029/732 H01L029/737.ipc. H01L031/0328 H01L031/328 H01L031/336.ipc.)	USPAT; US-PGPUB	2004/03/24 12:45
2	11	(((trench\$2 groove\$3 window\$2 recess\$2)and(sige silicon near2 germanium))and(compris\$4 form\$4 depos\$4 fill\$4 dislocation\$4 defect\$4 facet\$2))and (lithograph\$4 etch\$4) and emitter and (H01L029/70 H01L029/732 H01L029/737.ipc. H01L031/0328 H01L031/328 H01L031/336.ipc.)	EPO; JPO; DERWENT	2004/03/24 12:46
-	59	((sige silicon near2 germanium)near33(non\$1recess\$4 recess\$2))	USPAT; US-PGPUB	2004/03/24 12:44
-	5180	((sige silicon near2 germanium)near13(fill\$3 depost\$3 form\$4))	USPAT; US-PGPUB	2004/03/15 22:56
-	124	((sige sige silicon near2 germanium)near21(corner\$4 edg\$2))	USPAT; US-PGPUB	2004/03/15 22:56
-	8	(((sige silicon near2 germanium)near33(non\$1recess\$4 recess\$2))) and (((sige silicon near2 germanium)near13(fill\$3 depost\$3 form\$4))) and (((sige sige silicon near2 germanium)near21(corner\$4 edg\$2)))	USPAT; US-PGPUB	2004/03/15 22:52
-	8	(((sige silicon near2 germanium)near33(non\$1recess\$4 recess\$2))) and ((sige sige silicon near2 germanium)near21(corner\$4 edg\$2)))	USPAT; US-PGPUB	2004/03/15 22:51
-	45	(((sige silicon near2 germanium)near33(non\$1recess\$4 recess\$2))) and (((sige silicon near2 germanium)near13(fill\$3 depost\$3 form\$4)))	USPAT; US-PGPUB	2004/03/15 22:51
-	80	(((sige silicon near2 germanium)near13(fill\$3 depost\$3 form\$4))) and (((sige sige silicon near2 germanium)near21(corner\$4 edg\$2)))	USPAT; US-PGPUB	2004/03/15 22:52
-	72	((((sige silicon near2 germanium)near13(fill\$3 depost\$3 form\$4))) and (((sige sige silicon near2 germanium)near21(corner\$4 edg\$2)))) not (((sige silicon near2 germanium)near33(non\$1recess\$4 recess\$2))) and (((sige silicon near2 germanium)near13(fill\$3 depost\$3 form\$4)))	USPAT; US-PGPUB	2004/03/15 22:52
-	57	((sige silicon near2 germanium)and(non\$1recess\$4 recess\$2))	EPO; JPO; DERWENT	2004/03/15 22:56
-	20297	((sige silicon near2 germanium)and(fill\$3 depost\$3 form\$4))	USPAT; US-PGPUB	2004/03/15 22:57
-	120	((sige sige silicon near2 germanium)and(corner\$4 edg\$2))	EPO; JPO; DERWENT	2004/03/15 22:57
-	4276	((sige silicon near2 germanium)and(fill\$3 depost\$3 form\$4))	EPO; JPO; DERWENT	2004/03/15 22:57
-	8	(((sige silicon near2 germanium)and(non\$1recess\$4 recess\$2))) and (((sige sige silicon near2 germanium)and(corner\$4 edg\$2))) and (((sige silicon near2 germanium)and(fill\$3 depost\$3 form\$4)))	EPO; JPO; DERWENT	2004/03/15 22:57
-	129	(((trench\$2 groove\$3 window\$2)near21(sige silicon near2 germanium))same(compris\$4 form\$4 depos\$4 fill\$4 dislocation\$4 defect\$4)) and (lithograph\$4 etch\$4) and emitter	USPAT; US-PGPUB	2004/03/23 19:46
-	8	(((trench\$2 groove\$3 window\$2)near21(sige silicon near2 germanium))same(facet edge\$2 corner\$2)) and (lithograph\$4 etch\$4) and emitter	USPAT; US-PGPUB	2004/03/23 19:48
-	10	(((opening\$2)near21(sige silicon near2 germanium))same(facet edge\$2 corner\$2)) and (lithograph\$4 etch\$4) and emitter	USPAT; US-PGPUB	2004/03/23 19:50
-	2	(((opening\$2)and(sige silicon near2 germanium))and(facet edge\$2 corner\$2)) and (lithograph\$4 etch\$4) and emitter	EPO; JPO; DERWENT	2004/03/23 19:51
-	16	(((trench\$2 groove\$3 window\$2)near21(sige silicon near2 germanium))and(compris\$4 form\$4 depos\$4 fill\$4 dislocstion\$4 defect\$4 facet\$2))and (lithograph\$4 etch\$4) and emitter	EPO; JPO; DERWENT	2004/03/23 19:55
-	4	(((trench\$2 groove\$3 window\$2)near21(sige silicon near2 germanium))and(edge\$2 corner\$2))and (lithograph\$4 etch\$4) and emitter	EPO; JPO; DERWENT	2004/03/23 19:55